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**Center for Space Power and Advanced Electronics
Auburn University**

**Dr. Dan Deis
Manager of Engineering Science**

**Dr. Richard Hopkins
Manager of Electro-Optical Materials**

Westinghouse Science and Technology Center

VALUE OF PARTICIPATION IN A CCDS TO AN INDUSTRIAL PARTNER

Dr. D. W. Deis

Dr. R. H. Hopkins

Westinghouse Science & Technology Center

Member of
NASA/Auburn University CCDS;
Center for Space Power and Advanced Electronics

NASA Office of Commercial Projects
Washington, DC
May 14, 1991



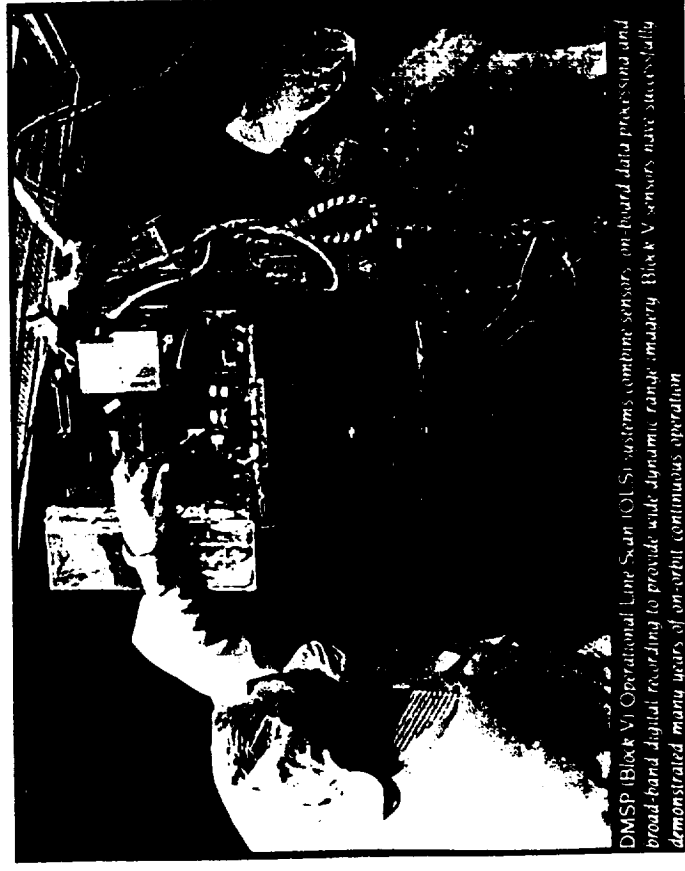
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Westinghouse Is Involved In Space Activities: Its Commercial Activities Are Expanding As A Result Of Its CCDS Participation



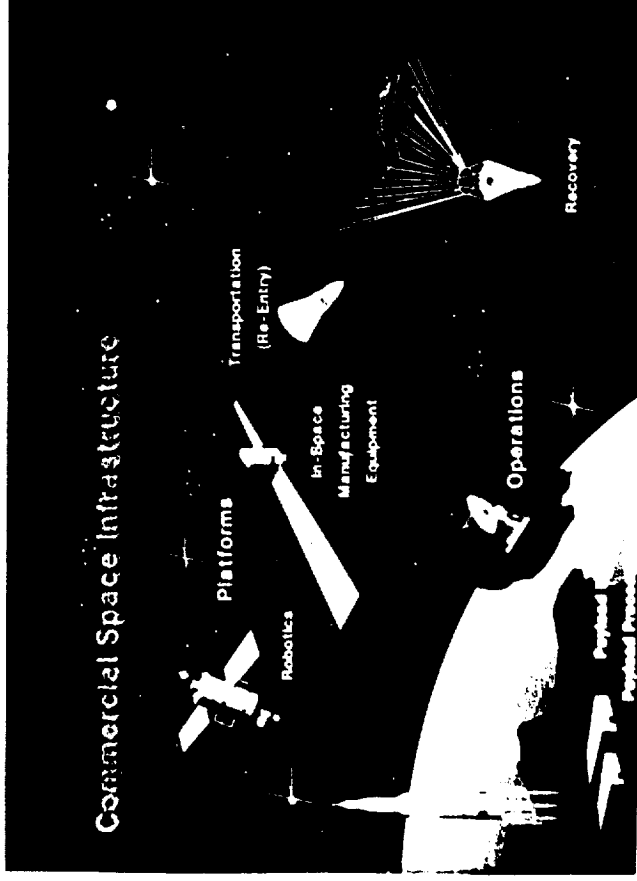
- Space Division
- Commercial & Civil Space Dept.
- Science & Technology Center
- NASA CCDS's

The Westinghouse Space Division Applies Its Advanced Electronic Capability to the Analysis, Design, Development Production and Support of Space Related Missions



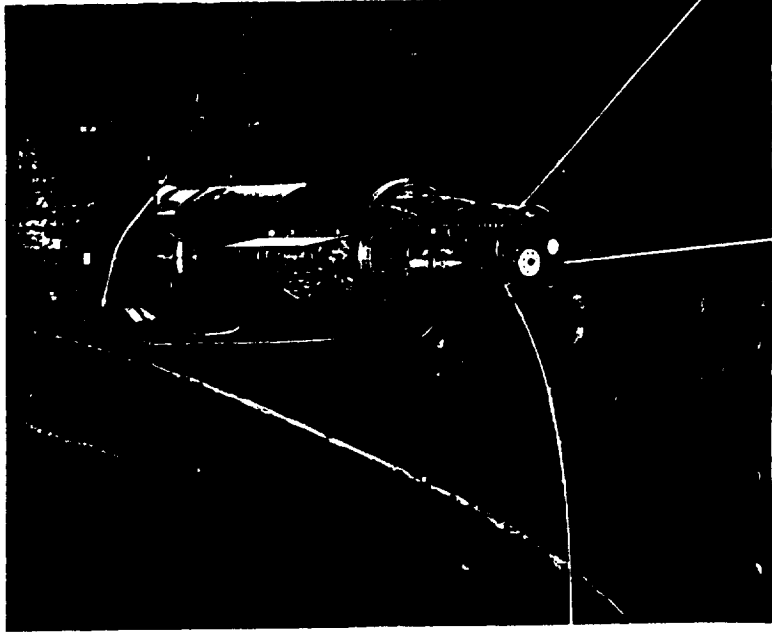
- Earth Observation Sensors
- Control and Data Management
- Signal Processing
- Space Defense

The Westinghouse Commercial & Civil Space Department Is Committed to Development the Infrastructure for Low Cost Access to Space



- Responsible for the Systems Engineering and Service Module for the COMET project.
- Operates Astro Tech for payload processing.
- Will actively pursue all aspects of commercial launch, on-orbit services, and recovery.
- Maintains active interactions with several CCDS's.

The Westinghouse Science & Technology Center Develops Products & Technologies for Westinghouse Divisions



Major Space Activities

- SPEAR Program
- Hyper-Conductor Generator
- TEM-Pump for SP-100
- Space Furnaces
- SMES Program
- Participation in CCDS's
 - Auburn
 - Clarkson

Westinghouse, In Conjunction With The Auburn CCDS, Is Developing Space Related Products and Technologies

Products:

Intelligent fault protection system based on neural network technology

- Critical element of adaptive (autonomous) controls for electrical power systems and components.
- Terrestrial applications can expedite commercialization.

Technologies:

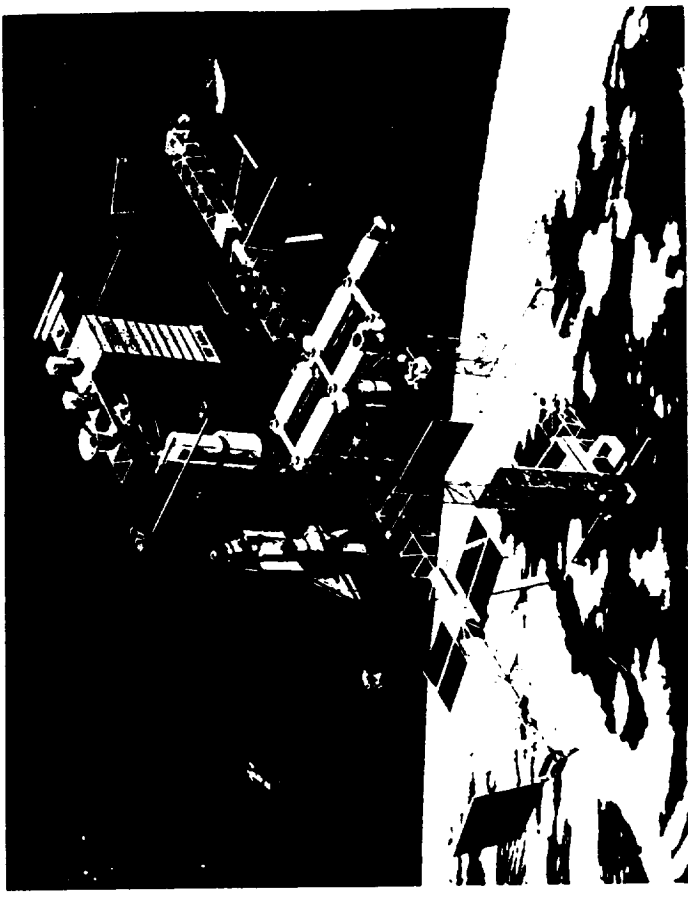
- High temperature, radiation-hard electronics based on SiC
- Enabling technology for highly reliable and long-lived space based electronics.
 - Extensive commercial and military applications.



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Intelligent Adaptive Controls Can Improve The Reliability of Space Power Systems

- Minimizing human response time and errors in correcting faults, and properly interpreting fuzzy sensor signals.
- High level autonomous operation
- Detecting incipient faults
- Impact
 - Improved availability
 - Reduced fault severity
 - Reduced maintenance time



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The Development of the Product Need, Concept and Implementation Has Utilized Significant University Participation

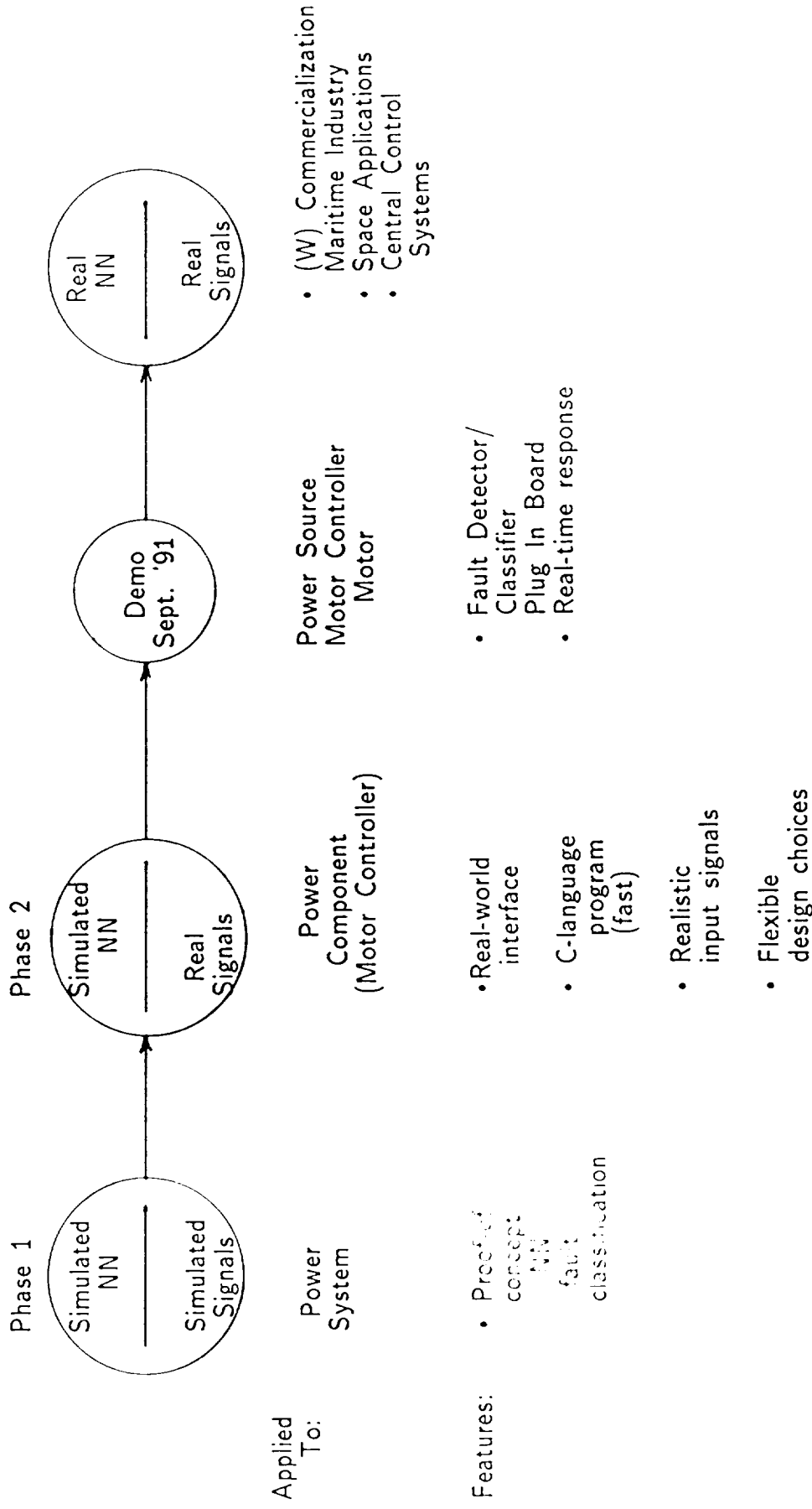
W - STC

- Selection of neural network applications
- Integration of neural network with hardware
- Training of neural network with data
- Laboratory set-up and demonstration
- Commercialization

Auburn U

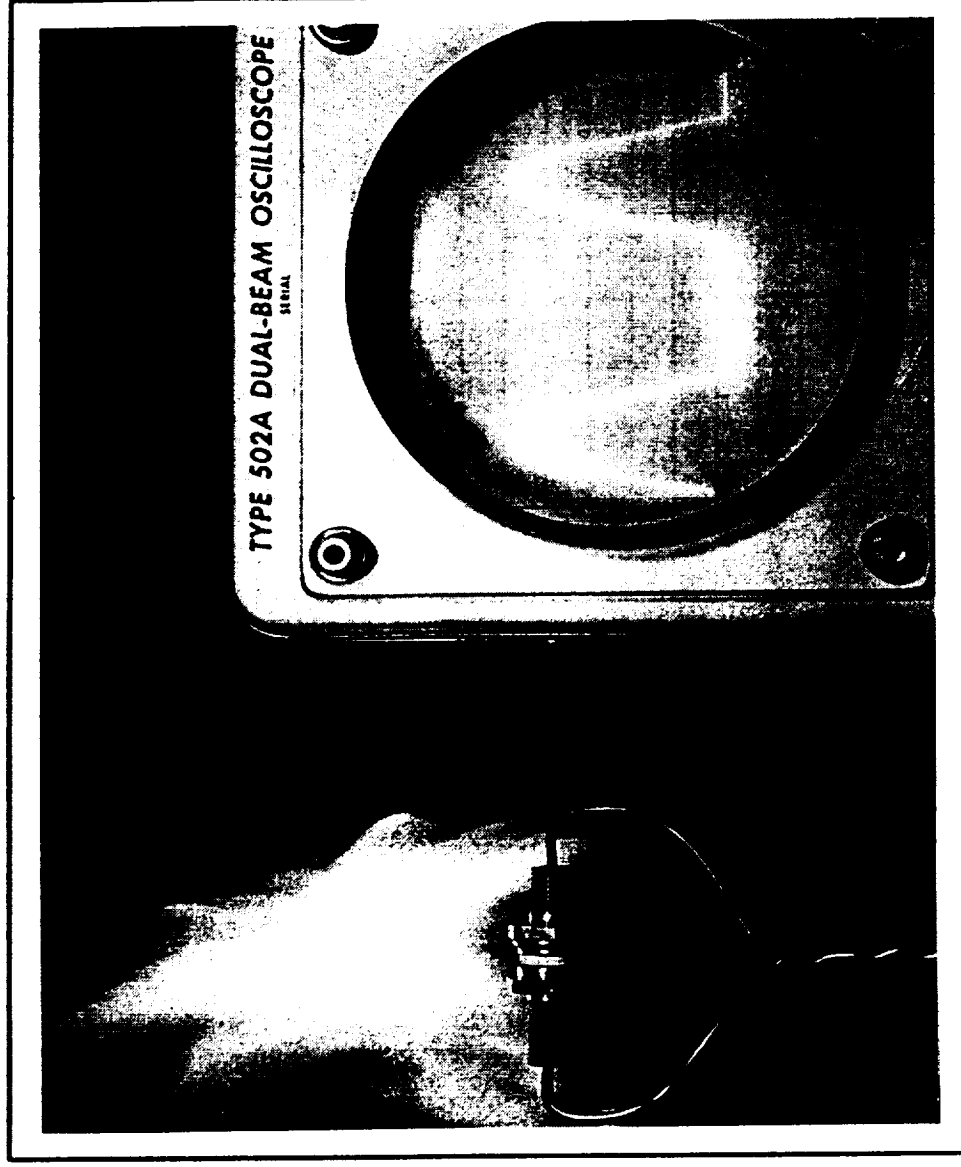
- Consultation on neural network techniques
- Development of user-friendly neural network software
- Development of parallel processor computer system on card
- Awareness of current developments in neural network hardware and paradigms

Intelligent Fault Protection Development Accomplishments and Status



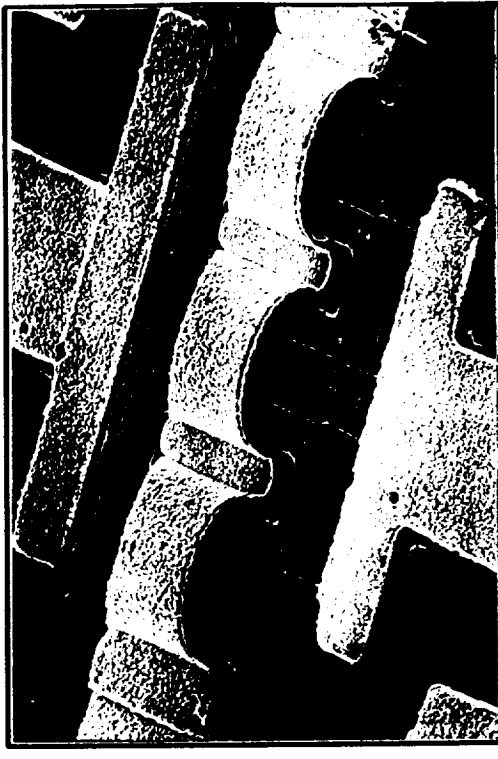
Silicon Carbide (SiC) - The Semiconductor With the Right Stuff

**Rectification in a
Hot, Chemically
Active
Environment**



SILICON CARBIDE ELECTRONICS

- **High Temperature, RAD Hard Devices are an Enabling Technology for Advanced Ultrareliable Space Electronics**
 - **Secure, Uninterrupted Satellite Communications**
 - **Significant Reduction in Satellite Payload Cooling and Weight**
 - **Compact Reactor Diagnostics and Thrust Controls for SEI Missions**



- **Silicon Carbide is a Pervasive Technology with Many Commercial Applications**

Silicon Carbide Beats Nearest Competitor

High Power

- 10X Power Density
 - Reduced Parts, Size, Cost
 - New Capabilities: Stealth Detection

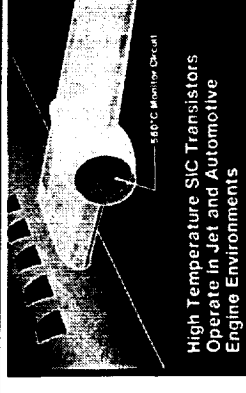
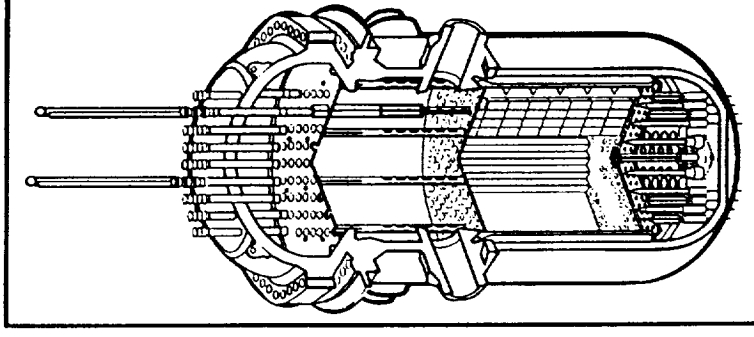
High Temperature

- 650° Operation vs. 150°
 - Less Cooling, Weight, System Cost
 - 1,000X Reliability

Radiation Hard

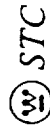
- 20X Gamma, 50X Neutron Resistance
 - First In-Core Electronics for Protection and Control
 - Reduced Cabling, Penetrations and Cost
 - New Services

Transistors for Long-Range Surveillance



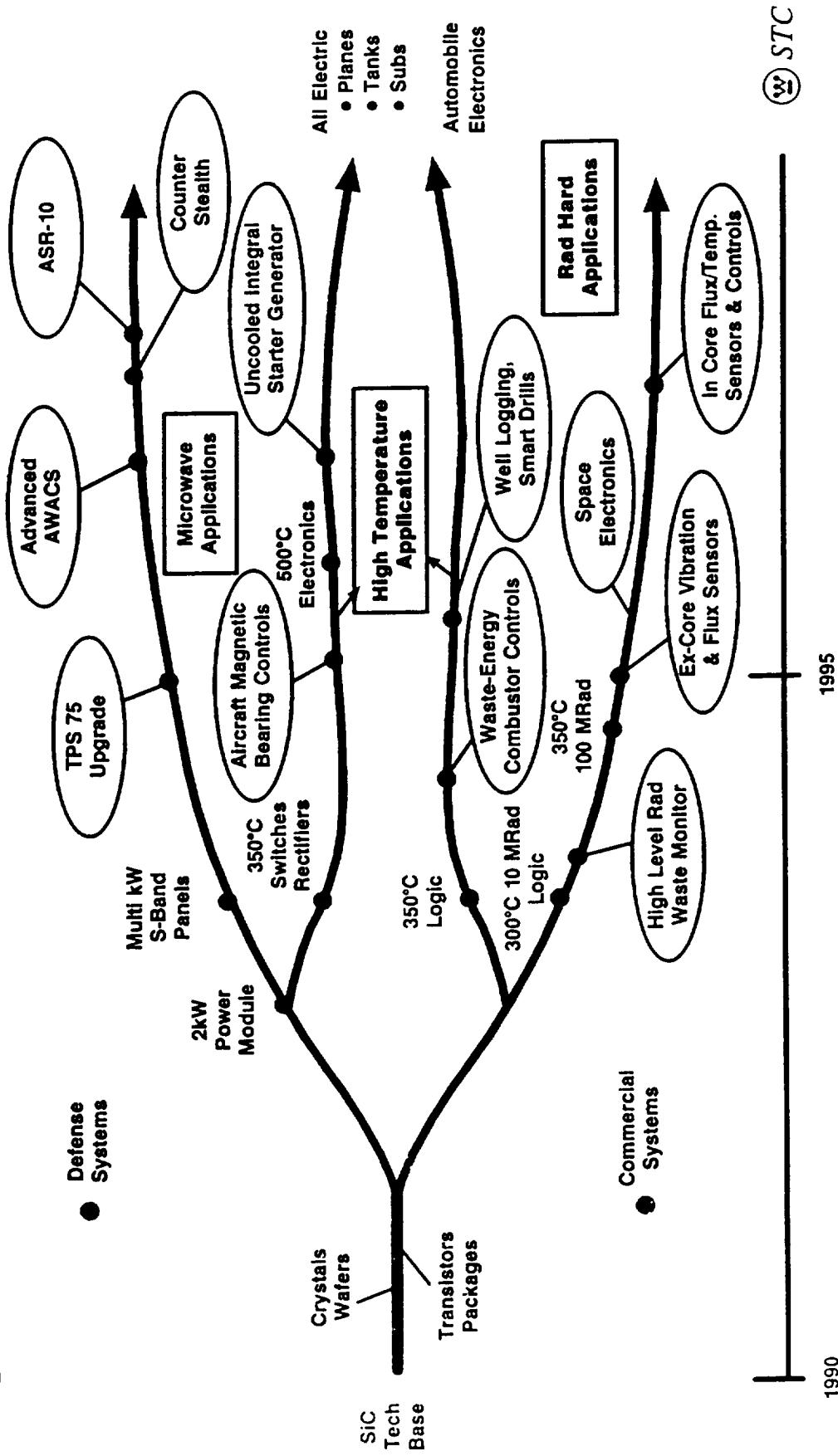
**Electronics in
Severe Environments:
All-Electric Vehicles**

**In-Core Flux and
Temperature Measurements
at 100 MRad 350°**



Silicon Carbide Payoff

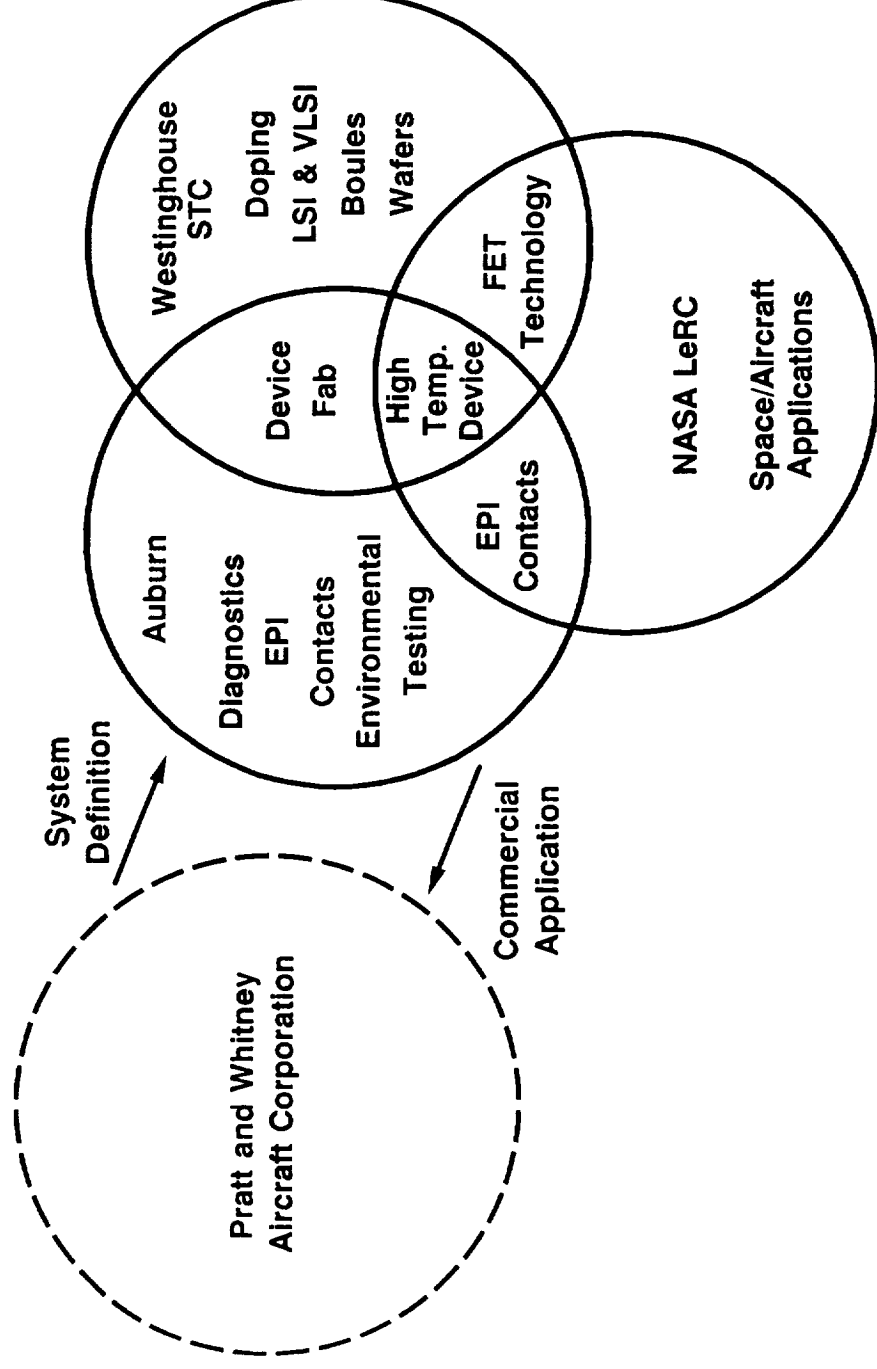
Significant New Business



STC

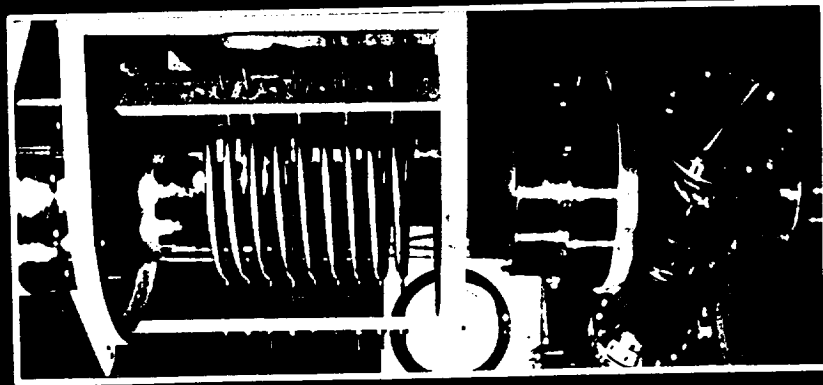
THE AUBURN CCDS PARTNERSHIP

Complementary Skills Linked to Accelerate Silicon Carbide Electronics to Commercialization

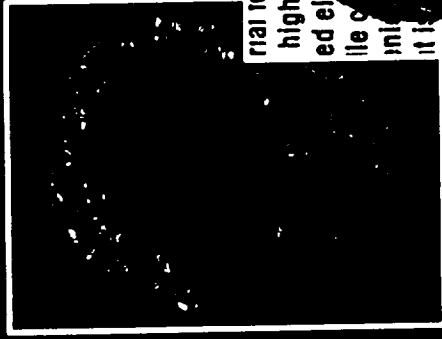


SIC CRYSTAL GROWTH

- High Power Microwave
- High Temperature Microelectronics
- Rad Hard Devices



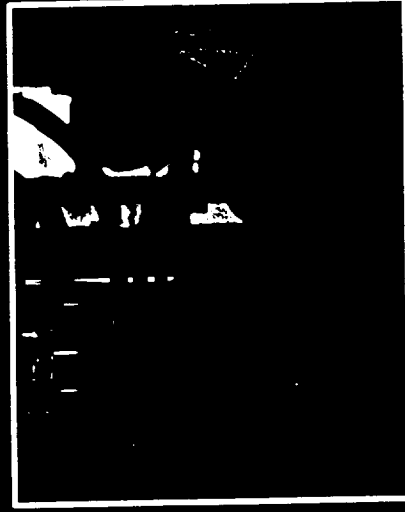
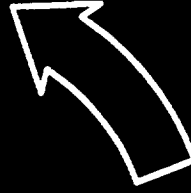
High Purity Growth System



Boule

Wafer

material for fabrication of high power high temperature electronic systems. It is a high temperature material which can be used in a wide range of applications. It is a high temperature material which can be used in a wide range of applications. It is a high temperature material which can be used in a wide range of applications.

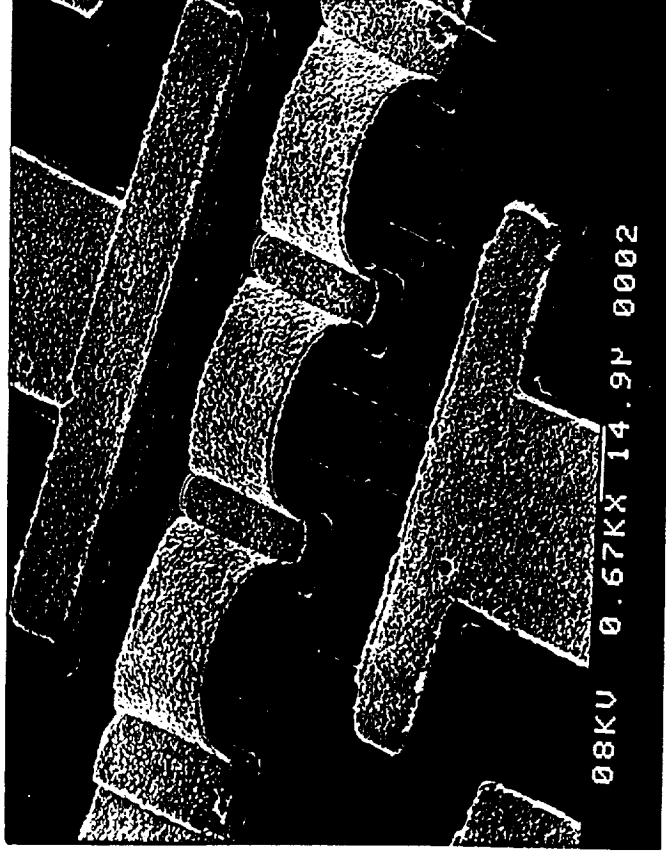


Vapor Transport Growth

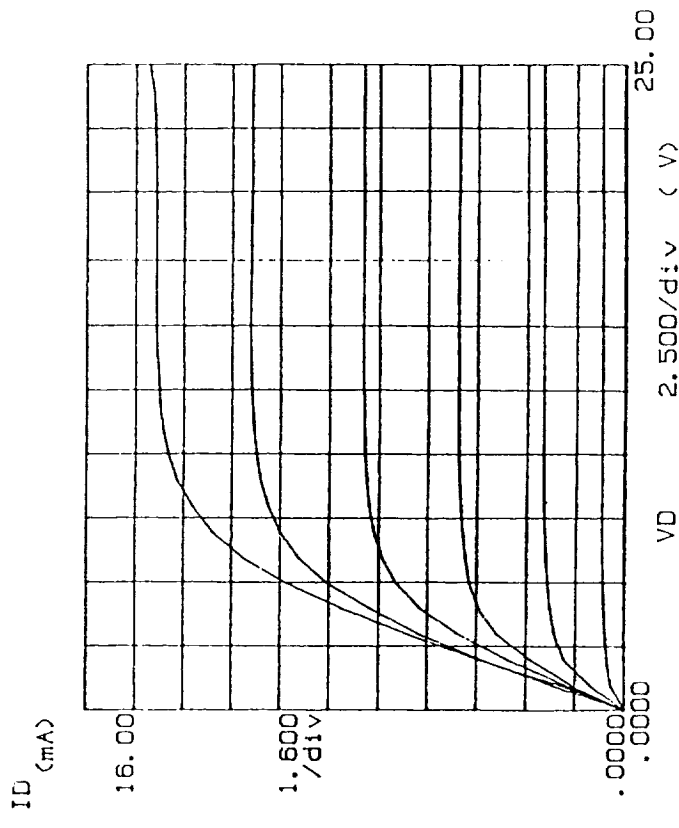


SiC Device Development At STC For Microwave Power Transistors

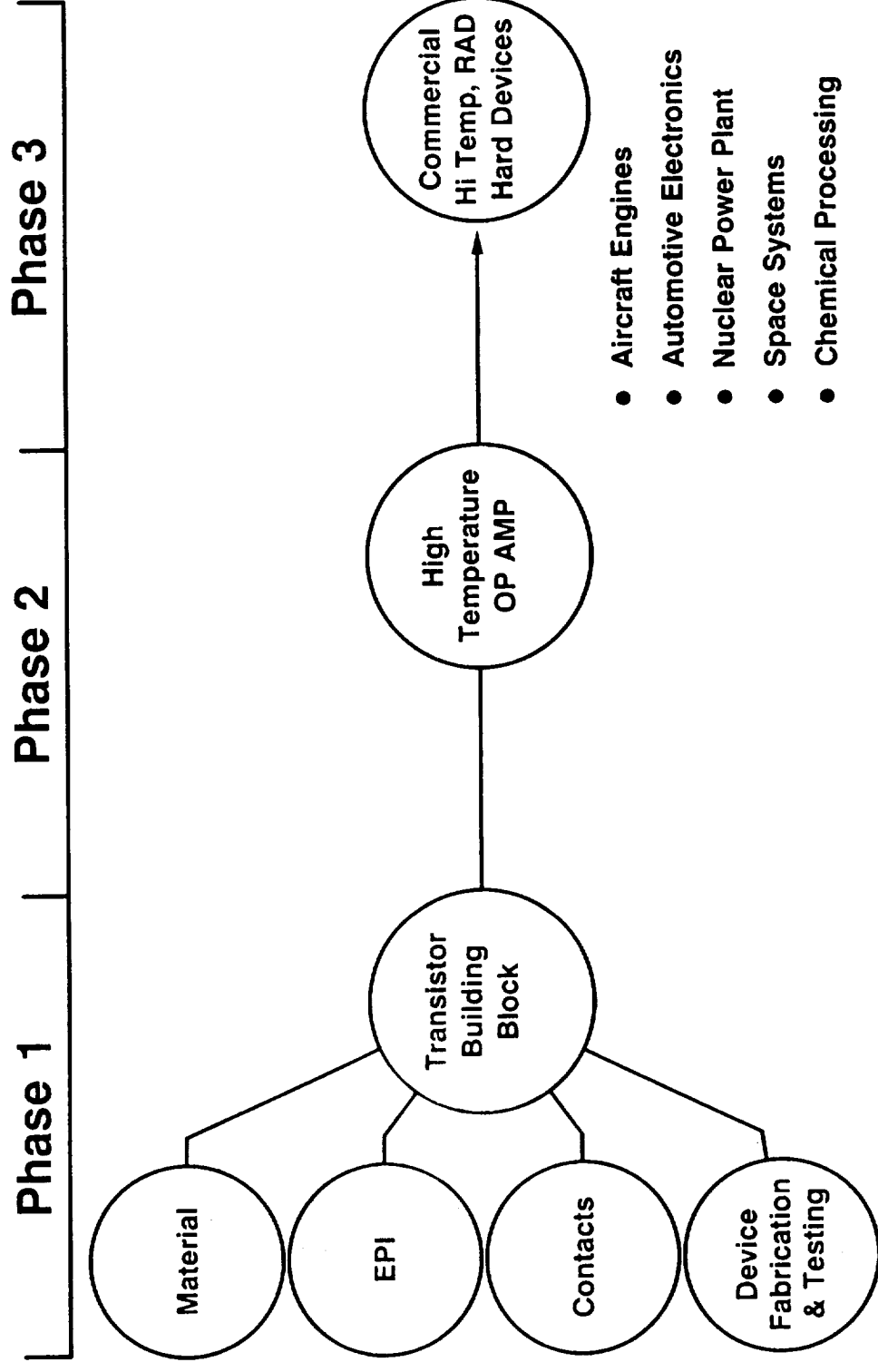
6-Gate μ -Wave Transistor



dc Characteristics

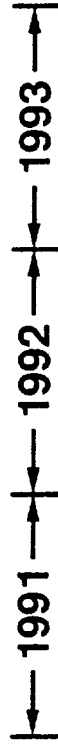


A SILICON CARBIDE MICROELECTRONIC DEVICE DEVELOPMENT PATH HAS BEEN DEFINED



THE CCDS PROGRAM WAS INITIATED IN 1991

Goal: Devices that Operate at 200-500°C with Acceptable Lifetime



Boule Growth Wafer Production	WEC	<p>FCE Upgrade 1.0 Diam. 2.0 Diam. High Quality</p>
EPI Layer Formation	Auburn WEC/LeRC	<p>Reactor Design 1" Reactor Operational 2" Advanced EPI Defined for High Uniformity 3"</p>
Hot Implantation	WEC	<p>Define Baseline Uniform N⁺ Junctions Demo P⁺ High Activation 400°C Stable Junctions</p>
Diagnostics & Theoretical Support	Auburn	
Contacts	Auburn WEC	<p>Define Baseline Define Baseline (Al,Ni) Test Contacts Demo 400°C Operation</p>
Device Design/Fab	Auburn WEC	<p>Define Device Mod 1 FET (Defined) 200°C Upgrade 300°C 400°C</p>

THE CCDS SILICON CARBIDE EFFORT IS ON SCHEDULE

- Working Relationships Established
 - First Exchange of Devices and Test Data Accomplished

Auburn

5 Faculty, 4 Students

Staff
Committed

Topics

Structure Modeling
Contact Metalization Systems
Advanced Epitaxy Techniques
SiC Growth Kinetics
Surface Chemistry
Structural Diagnostics

Status

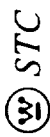
- RBS Analysis of Initial WEC Contact System
- Design of New EPI Reactor Initiated
- Polytype Stability Calculations Made

Westinghouse

6 Scientists, 4 Technical Support

- Boule Growth Scale-Up
- Low Defect Wafer Production
- Hot Ion Implantation Junction Formation
- Device Design / Fabrication

- Furnace Scale-Up Design Complete
- Furnace Fabrication Initiated
- Successful 1.5" Diameter Boule Growth



The NASA-CCDS at Auburn University Has Met All of Westinghouse's Expectations

- Excellent leadership.
- Impressive R&D programs.
- Stimulation of University environment - participation of students.
- Full cooperation of industrial partners.
- Cooperative participation by government labs.
- Opportunity to develop, in partnership with Auburn University, technologies and components for space.



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